

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

December 17, 2024

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG670410981

LABORATORY GROWN DIAMOND

EMERALD CUT

7.83 X 5.54 X 3.80 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

1.59 CARAT

E

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

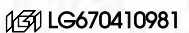
EXCELLENT

EXCELLENT

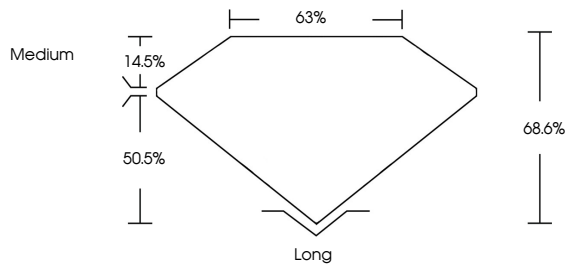
NONE

Inscription(s)

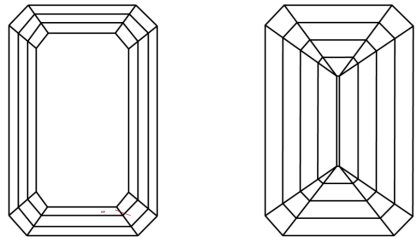
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



PROPORTIONS



CLARITY CHARACTERISTICS




KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

LABORATORY GROWN DIAMOND REPORT



December 17, 2024

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG670410981

LABORATORY GROWN DIAMOND

EMERALD CUT

7.83 X 5.54 X 3.80 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

1.59 CARAT

E

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

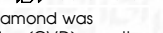
EXCELLENT


EXCELLENT

NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa





IGI

December 17, 2024

IGI Report No LG670410981

EMERALD CUT

7.83 X 5.54 X 3.80 MM

Carat Weight

Color Grade

Clarity Grade

Depth

Table

Girdle

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

1.59 CARAT

E

VS 1

68.6%

63%


Medium

Long



EXCELLENT

EXCELLENT

NONE




Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



© IGI 2020, International Gemological Institute

FD - 10 20



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.